

**INVENTOR'S DECLARATION FOR
PATENT APPLICATION**

As below named inventors, we hereby declare that:

Our residence, post office address and citizenship are as stated below next to our names;

We believe we are the original, first and sole joint inventors of the subject matter which is claimed and for which a patent is sought on the invention entitled

SURFACE DISTORTION COMPENSATED PHOTOLITHOGRAPHY

the specification of which: (check one)

 X is attached hereto.
 was filed on _____
under Attorney's Docket Number _____
as Application Serial No. _____
and was amended on _____ (if applicable).

We hereby state that we have reviewed and understand the contents of the above identified specification, including the claims, as amended by any amendment referred to above.

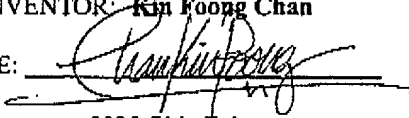
We acknowledge the duty to disclose information which is material to the patentability of this application in accordance with 37 CFR 1.56.

We hereby declare that all statements made herein of our own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under 18 USC 1001 and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

This patent is a continuation-in-part of the utility application listed below.

09/918,732 July 31, 2001
(Application Number) (Filing Date)

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:	Kin Foong Chan, et al.	§	
		§	
		§	Group Art Unit: n/a
Serial No.:	n/a	§	
		§	
Filed: Herewith		§	Examiner: n/a
		§	
For:	SURFACE DISTORTION COMPENSATED	§	
	PHOTOLITHOGRAPHY	§	

Commissioner for Patents
Washington, D.C. 20231

POWER OF ATTORNEY FOR
PATENT APPLICATION

As a representative of the Assignee, Ball Semiconductor, Inc., a Texas corporation, I hereby appoint the following attorneys and/or agents to prosecute this application and transact all business in the Patent and Trademark Office connected therewith.

David L. McCombs (Reg. No. 32,271); Michael J. Balconi-Lamica (Reg. No. 34,291); Jeffrey M. Becker (Reg. No. 35,442); J.R. Bell (Reg. No. 26,528); Theodore Baroody (Reg. No. 45,417); L. Howard Chen (Reg. No. 46,615); Randall E. Colson (Reg. No. 40,566); Michael A. Davis, Jr. (Reg. No. 35,488); Ruben C. DeLeon (Reg. No. 37,812); Brian J. Hubbard (Reg. No. 45,873); Rita M. Irani (Reg. No. 31,028); Mark P. Kahler (Reg. No. 29,178); Warren B. Kice (Reg. No. 22,732); Christopher P. Kosh (Reg. No. 42,760); J. Andrew Lowes (Reg. No. 40,706); Todd Mattingly (Reg. No. 40,298); John Montgomery (Reg. No. 31,124); Bill R. Naifeh (Reg. No. 44,962); David M. O'Dell (Reg. No. 42,044); and Phillip B. Philbin (Reg. No. 35,979).

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The undersigned is the representative for the Assignee of the entire right, title, and interest in the patent application identified above. A copy of the assignment or other documents in the chain of title are attached.

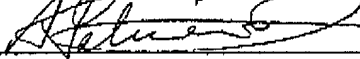
Patent / Docket No.: 22397.266
USPTO Customer No. 27683

The undersigned (whose title is supplied below) is authorized to act on behalf of the Assignee.

December 20, 2001
Date

BALL SEMICONDUCTOR, INC.

Akira Ishikawa
Typed or printed name


Signature

Chairman, President & CEO
Title